

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of

Inventor : Gurtej S. Sandhu
Serial No. :
Filed :
Title : **ATOMIC LAYER DEPOSITION WITH POINT
OF USE GENERATED REACTIVE GAS SPECIES**
Docket No. : MIO 0092 VA/ 01-0791.01

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

OFFICIAL COMMUNICATION

This Official Communication is in regard to the divisional application filed herewith, which claims priority to currently pending Application Serial No. 10/091,938, filed March 5, 2002.

This divisional application was filed in the present case by filing a new specification with new claims, along with the oath or declaration from the prior (parent) application pursuant to 37 CFR §1.53(b). The text of the newly filed specification includes changes to the title, specification, and abstract as originally filed in the parent application from which this division claims priority.

For the convenience of the Examiner, enclosed herewith is a marked-up version of the new specification showing the changes made. The changes made thereto do not introduce new matter. Rather, the changes are presented to update the status of the application and to provide clarity.

Applicants respectfully submit that the claims of the present divisional application represent allowable subject matter. The Examiner is encouraged to contact the undersigned to resolve efficiently any formal matters or to discuss any aspects of the application or of this Official Communication. Otherwise, early notification of allowable subject matter is respectfully solicited.

Respectfully submitted,
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